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APPLICATION NO	FILING DATE		FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO
09 500,288	02 08 2000		Shinichi Nagahama	NICHIA-00800	2385
23117	7590	03 31 2003			
NIXON & VANDERHYE, PC				EXAMINER	
1100 N GLEB 8TH FLOOR		=	LOUIE, WAI SING		
ARLINGTON, VA 22201-4714				ART UNIT	PAPER NUMBER
				2814	

DATE MAILED: 03/31/2003

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)
	09/500.288	NAGAHAMA ET AL
Office Action Summary	Examiner	Art Unit
,	Wai-Sing Louie	2814
The MAILING DATE of this communic		
Period for Reply		
A SHORTENED STATUTORY PERIOD FO THE MAILING DATE OF THIS COMMUNIC - Extensions of time may be available under the provisions o after SIX (6) MONTHS from the mailing date of this commu - If the period for reply specified above is less than thirty (30) - If NO period for reply is specified above, the maximum state - Failure to reply within the set or extended period for reply w - Any reply received by the Office later than three months aft earned patent term adjustment See 37 CFR 1 704(b)	CATION: f 37 CFR 1 136(a) In no event, however, may nication. idays, a reply within the statutory minimum of utory period will apply and will expire SIX (6) Note that the cause the application to become	y a reply be timely filed thirty (30) days will be considered timely MONTHS from the mailing date of this communication a ABANDONED (35 U.S.C. § 133)
Status 1) Responsive to communication(s) file	id on 30 January 2003	
_	b) This action is non-final.	
24/23	<i>,</i> —	matters, prosecution as to the merits is
3) Since this application is in condition closed in accordance with the praction of Claims	ce under Ex parte Quayle, 1935	C.D. 11, 453 O.G. 213.
4) \boxtimes Claim(s) <u>17-22</u> is/are pending in the	application.	
4a) Of the above claim(s) is/are	e withdrawn from consideration.	
5) Claim(s) is/are allowed.		
6)⊠ Claim(s) <u>17-22</u> is/are rejected.		
7) Claim(s) is/are objected to.		
8) Claim(s) are subject to restrict	tion and/or election requirement.	
Application Papers		
9) The specification is objected to by the		
10) The drawing(s) filed on is/are:	a) accepted or b) objected to b	by the Examiner.
Applicant may not request that any obje	ection to the drawing(s) be held in al	beyance. See 37 CFR 1.85(a).
11) The proposed drawing correction filed		disapproved by the Examiner.
If approved, corrected drawings are req		
12) The oath or declaration is objected to	by the Examiner.	
Priority under 35 U.S.C. §§ 119 and 120		0 5 440(a) (d) or (f)
13) Acknowledgment is made of a claim	for foreign priority under 35 U.S.	C. § 119(a)-(d) or (1).
a)⊠ All b)□ Some * c)□ None of:		
	documents have been received.	in Application No.
	documents have been received	
3. Copies of the certified copies of application from the Intern * See the attached detailed Office action	ational Bureau (PCT Rule 17.2(a	een received in this National Stage a)). not received.
14) Acknowledgment is made of a claim for		
a) The translation of the foreign lan	iguage provisional application ha	as been received.
Attachment(s)		
Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (P 3) Information Disclosure Statement(s) (PTO-1449) P	TO-948) 5) Notice	view Summary (PTO-413) Paper No(s)e of Informal Patent Application (PTO-152)

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DETAILED ACTION

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claim 17 is rejected under 35 U.S.C. 103(a) as being unpatentable over Hong et al. (US 6.177.292) in view of Koide (JP 11-145516) and Kern et al. (US 6.194.742).

With regard to claim 17. Hong et al. disclose gallium nitride semiconductor diode (col. 4. line 3 to col. 11, line 64 and fig. 7) comprising:

A GaN substrate 70 having a single-crystal GaN on its surface. Hong et al. do not disclose the single-crystal GaN layer 70 is formed through a lateral-growth process. However, Koide disclose a lateral growth method to form a GaN layer 3 on a sacrificial Si substrate. The GaN layer 3 would epitaxially grow in vertical as well as laterally direction (Koide [0001] to [0005] and fig.1). Koide teaches the lateral grow method would not generate cracks and dislocation within the GaN layer (Koide [0004]). Therefore, it would have been obvious to one with ordinary skill in the art to modify Hong's device with the teaching of Koide to provide a lateral grow GaN layer on the substrate 70. Doing so would avoid forming cracks in the GaN layer:

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- Hong et al., modified by Koide above, would disclose a small crack preventing layer 2 made of Al_aGa_{1-a}N (0<a<0.15) and contacting the substrate (Koide [0015] and fig. 1). Although, the mole fraction of aluminum is not 0<a<0.1 as claimed. However, in the case where the claimed ranges "overlap or lie inside the ranges disclosed by the prior art" a prima facie case of obviousness exists (In re-Wetheim, 541 F2d 257, 191 USPQ 90 (CCPA 1976); In re Woodruff, 919 F2d 1575, 1578, 16 USPO2d 1934, 1936 (Fed. Cir. 1990)). Similarly, a prima facie case of obviousness exists where the claimed ranges and the prior art ranges do not overlap but are close enough that one skill in the art would have expected them to have the same properties (Titanium Metals Corporation of America v. Banner. 778 F.2d 775, 227 USPQ 773 (Fed. Cir. 1985); See MPEP 2144.05). Hong et al. do not disclose the AlGaN laver has a coefficient of thermal expansion less than that of GaN substrate. However, Kern et al. disclose a LED having an AlGaN device-forming layer (interfacial layer 16). Kern et al. disclose the coefficient of thermal expansion of GaN and AlN (see col. 2, table 1). By estimation, the coefficient of thermal expansion of Al_aGa_{1-a}N is about 4.45x10⁻⁶ /K, when a=0.1. The coefficient of thermal expansion of AlGaN layer is. therefore, less than GaN substrate thereby providing compression strain on the AlGaN crack-preventing layer (Kern col. 4, lines 29-32):
- An n-type cladding layer 71 containing Al (fig. 7):
- An active layer 72 containing InGaN (fig. 7):
- A p-type cladding layer 73 containing Al (fig. 7).

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With regard to claim 18, Hong et al., modified by Koide in claim 17 above, disclose the n-type cladding layer 71 contains more Al than the small crack-preventing layer (col. 10, lines 25-26).

With regard to claims 19-20. Hong et al., modified by Koide in claim 17 above, disclose the small crack-preventing layer 2 has a thickness of 5 micron (Koide [0015]).

With regard to claim 21. Hong et al., modified by Koide in claim 17 above, disclose the small crack-preventing layer 2 has been grown without an impurity doping (Koide [0015] to [0016]).

With regard to claim 22 and in according to claim 17 above. Hong et al. disclose an InGaN layer 52 is intervened between the small crack-preventing layer and the n-type cladding layer (fig. 5).

Response to Arguments

Applicant's arguments with respect to claims 9-16 have been considered but are moot in view of the new ground(s) of rejection.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Wai-Sing Louie whose telephone number is (703) 305-0474. The examiner can normally be reached on 7:30 AM to 4:00 PM.

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If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor. Wael Fahmy can be reached on (703) 308-4918. The fax phone numbers for the organization where this application or proceeding is assigned are (703) 308-7722 for regular communications and (703) 308-7722 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0956.

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